

APR 2 0 2005

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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Cécile AULNETTE et al.

Confirmation No.: 7888

IFW

Application No: 10/763,978

Group Art Unit: 2814

Filing Date: January 22, 2004

Examiner: D. Wille

For: SEMICONDUCTOR STRUCTURE FOR

Atty. Docket No.: 4717-7300

PROVIDING STRAINED CRYSTALLINE LAYER ON INSULATOR AND METHOD FOR FABRICATING

**SAME** 

## RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

In response to the Examiner's restriction requirement dated April 8, 2005, applicants elect, with traverse, the product claims of Group I, claims 1-12, for prosecution in this application.

It is believed that the entire application is in condition for allowance, early notice of which would be appreciated.

No fees are believed to be due for this submission. Please charge any required fees to Winston & Strawn LLP Deposit Account No. 50-1814.

Respectfully submitted,

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